	Туре	L #	Hits	Search Text	DBs	Time Stamp
1	IS&R	L1	879	("250/310").CCLS.	USPAT	2001/08/17 15:21
2	BRS	L2	125	1 and defect	USPAT	2001/08/17 15 <b>:</b> 21
3	BRS	L3	36	2 and monitor	USPAT	2001/08/17 15:35
4	BRS	L4	11	2 and classify	USPAT	2001/08/17 15:35

	Comments	Error Definition	Err ors
1			0
2			0
3			0
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	ט	1 [1 ]	Е	ocument	ID	Issue Date	Pages
1		×	US	6259960	В1	20010710	119
2		×	US	5986263	Α ·	19991116	44
3		×	US	5665968	A	19970909	36

	Title	Current OR	Current XRef
1	Part-inspecting system	700/110	250/306 ; 250/310 ; 700/108 ; 700/109
2	manufacturing method and its manufacturing line	250/310	250/307
2	utilizing the same Inspecting optical masks with electron beam microscopy	250/310	250/306 ; 250/307

	Retrieval Classif	Inventor	S	С	P	2	3	4	5
1		Inokuchi, Masayuki	Ø	_		☒			
2		Hiroi, Takashi , et al.		_					
3		Meisburger, Dan , et al.	⊠				⊠		

	บ	1	D	ocument	ID	Issue Dat	te Pages
1		×	US	6259960	B1	20010710	119
2			US	6259520	В1	20010710	16
3			US	6072574	Α	20000606	15
4			US	5659172	A	19970819	15
5			US	5550372	А	19960827	18

	Title	Current OR	Current XRef
1	Part-inspecting system	700/110	250/306 ; 250/310 ; 700/108 ; 700/109
2	Integrated circuit defect review and classification process	356/237.4	250/310 ; 356/237.5 ; 356/394
3	Integrated circuit defect review and classification process	356/237.4	250/310 ; 356/237.5 ; 356/394
4	Reliable defect detection using multiple perspective scanning electron microscope images	250/307	250/310 ; 382/145
5	Apparatus and method for analyzing foreign matter on semiconductor  wafers and for controlling the manufacturing process of semiconductor  devices		250/307

	Retrieval Classif	Inventor	S	U	P	2 [1 ]	3	4	5
1	·	Inokuchi, Masayuki	⊠			×			
2		Zeimantz, Lisa R.	⊠			☒			
3 .		Zeimantz, Lisa R.	⊠			×			
4 -		Wagner, Mark , et al.	×			⊠			
5		Yasue, Takao	⊠			$\boxtimes$			

	U	1	Document ID	Issue Date	Pages
1			US 5777327 A	19980707	9
2		⊠	US 5665968 A	19970909	36

	Title	Current OR	Current XRef
	Pattern shape inspection apparatus for forming specimen image on display	250/310	250/306
2	apparatus Inspecting optical masks with electron beam microscopy	250/310	250/306 ; 250/307

	Retrieval Classif	Inventor	Ø	U	₽	2	3 [1 ]	4	5
1		Mizuno, Fumio	$\boxtimes$				×		
2		Meisburger, Dan , et al.	⊠				⊠		

	Туре	L#	Hits	Search Text	DBs	Time Stamp
1	IS&R	L1	879	("250/310").CCLS.	USPAT	2001/08/17 15:21
2	BRS	L2	125	1 and defect	USPAT	2001/08/17 15:21
3	BRS	L3	36	2 and monitor	USPAT	2001/08/17 15:35
4	BRS	L4	11	2 and classify	USPAT	2001/08/17 15:47
5	BRS	L5	327	1 and (monitor or crt or "cathode ray tube")	USPAT	2001/08/17 15:48
6	BRS <u></u>	L6	143	5 and images	USPAT	2001/08/17 15:49
7	BRS	L7	37	2 and 6	USPAT	2001/08/17 15:54
8	BRS	Г8	12	6 and (joystick or mouse)	USPAT	2001/08/17 15 <b>:</b> 57

<b>N</b>			
	Comments	Error Definition	Err ors
1			0
2			0
3			0
4			0
5			0
6			0
7			0
8			0